



Sicherheit in Technik und Chemie



Bundesministerium für Bildung und Forschung



GlasDigital - Data Driven Workflow for Accelerated Glass Development



www.bam.de

Abschlusstreffen 21.06.2024

GlasDigital Team

Authors



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Overview

- Motivation
- Concepts, ideas
- Cooperation
- Challenges

Glasses



Key components for advanced technologies







PV, OLED, photo- electrochromics, electronics/ optoelectronics, LTCC, fibres, precision components, bio/dental glass, optics, pharma, nuclear waste, seals and solders, pasts, H₂-barrier (tanks)...



- Continuous and widely adjustable properties
- Unique shaping techniques
- Ideal "tailored" material partner

VIA electronic

ttp://www.hilgenberg-ambh.de

Challenge Glass design



composition

- Complex property profiles
 E.g., SOFC glass seals:
 Thermal expansion
 Viscosity- and crystallization
- 😕 Too little **data**, no process data

Manual melting
 Time consumption
 Dangers
 Poor reproducibility..

Solution State State

- Stable micro structure at 850°C for 80.000h,
 - Adhesion \Leftrightarrow corrosion



https://i0.wp.com/www.h2-international.com/wp-content



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Digital infrastructure for accelerated glass development





Use case system $\mathbf{N}a_2\mathbf{O}-\mathbf{A}l_2\mathbf{O}_3-\mathbf{B}_2\mathbf{O}_3-\mathbf{S}i\mathbf{O}_2$

*HT = High throughput *ML = Machine learning





New casting and cooling system (since 7/23)

Casting on







6 Cooling

Casting and cooling system 2.0 (since 7/23)





Process data



③ High-throughput

© Reproducibility

© Process parameter

stored



"Experience"



{"date": "2022-07-02 16:11:04.061",

"recipe": "N115A15B615S255",

"material: ": "leer", "setpoint (g)": "0.0", "material: ": "test", "setpoint (g)": "0.0", "material: ":
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"setpoint (g)": "0.0", "material: ": "B2O3", "setpoint (g)": "33.01", "material: ": "K2O", "setpoint
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"fritten": "FALSE",

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Inline Sensors Furnace cameras





1350→1450°C 20K/min after 5th batch refill 30Na₂O - 10CaO - 60SiO₂ $\Delta t = 6:23 \min (10x time lap)$



Inline Sensors Real-time melting stage evaluation







1050°C, 10 fps, Sodium alumino silicate batch, Time to melt 300 s (10 x time lap)

Inline Sensors Real-time castability evaluation





1250°C, 30 fps, Sodium alumino silicate batch, (10x time lap)

Reflection of the furnace tube



- Mechanical impacts during continuous camera observation
- Image change rate scales with viscosity



Failure probability
 Reproducibility



Inline Sensors Casting





IR camera InfraTec VarioCAM HDx



Casting temperature and "choreography" → better homogeneity

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High-Throughput Analysis

Chemical composition ✓



PANanalytical Zetium Ultimate





XRF

- © Automated system at BAM 1.4
 - $(10 \min \text{ for } 5 \text{ elements} = 60 \text{ samples a day})$
- [©] Boron analysis
- → Combine with wet chemical B analysis
 → Combine it with LIBS (start in 2025)

	Composition [wt%]												
		Na ₂ O B A	B ₂ O ₃ B A	SiO ₂ B A									
ł	$N_{16}B_{10}S_{74}$	16,17 15,56	11,35 10,50	72,48 73,8									
÷	$N_{15}B_{35}S_{50}$	14,59 14,34	38,25 39,20	47,16 46,3									
ł	$N_{25}B_{25}S_{50}$	24,62 24,74	27,65 25,96	47,73 49,2									
ł	$N_{10}B_{40}S_{50}$	9,67 11,14	43,45 43,27	46,88 45,5									
ł	$N_{20}B_{30}S_{50}$	19,58 16,48	32,98 31,42	47,44 52,0									
i	$N_{16}B_{10}S_{74}$	16,17 15,59	11,35 10,94	72,48 73,1									
-	$N_{16}B_{10}S_{74}$	16,17 14,88	11,35 10,71	72,48 74,2									

 \approx 1.5 mol% accuracy (including $\Delta m = 0.05g$ dosing station)

High-Throughput Analysis Glass transition temperature T_a (\checkmark)





DSC Setaram Themys One+



No automated data processing



High-Throughput Analysis



Structural investigation (\checkmark)



(514 nm Ar, notch filter, 8-2000 cm⁻¹, D 1.3 cm⁻¹)

High-Throughput Analysis

Automated Raman data processing </



Python script:

- Data input (.txt files)
- Spectra normalization
- Band assignments
- Base line correction
- Peak fits, COG examination
- Feature extraction







High-Throughput Analysis Density (?)



Pycnometry

☺ Accuracy (0.02%) \bigcirc 10 min (T = const.) 8 Fully manual (No sampler, too difficult for cobots)



Anton Paar Ultrapyc 5000





3D Scanner

- © Fast measurement (Scan 1min)
- © Easy automatable
- Less accurate for large samples
- $(\Delta z = 35 \mu m \rightarrow \Delta V_{5 \times 5 \times 2 cm} = 0.3\%) (\rightarrow 0.1\%)$ \otimes Not yet automated data processing





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Process Modelling

S BAM



Digital twin





Prediction of casting & cooling parameters, casting choreography

Process Modelling Casting





Process Modelling



[Pan24] Pan et al., JNCS 627 (2024)

Process Modelling

S BAM

Inline viscosity measurement



Temperature measured with IR camera

Experimental viscosity data agree with their modelled counterparts for this temperature

Process Modelling Cooling





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Data Space Glass ontology



BFO Top-level



Glass ontology



https://github.com/ materialdigital/glasdi gital-ontology

 Compatibility to other materials and ontologies
 Permanent adjustments



https://git.material-digital.de/ya-fanchen/fast-ontodocker

Data Space

Semantic knowledge database





Data Space Data mining



Patent data extraction

- Ontology-based meta data, composition and property data from PDF text and tables
- User validation (extracted table vs. image)

		Pa Pa	atent Extraction Browse File or Patent URL	Würzburg server (dev)
	/Glachum -		Complete in 7.557 seconds.	
AN ANA ANA AN AN AN AN	IS00903446 Patent Extraction		□ Q 1 of 10 - + Automatic Zoom →	I 2 >> T Navigate
nited States Patent (10) Patent N urata (45) Date of TEMPERED GLASS SUBSTRATE AND ENTROD OF PRODUCING THE SAME (56) Inventor: Takashi Marata: Oraci (JP) 175,837 & 4855,87	No.: Patent Complete in 7.557 seconds. Referent S. PATENT Image: S. PATENT S. PATENT * 123 * 100 *	Würzburg server (dev) Ketelse	Construction Construction (19) United States (10) <td< th=""><th>Metadata Table 1 Table 2 Table 3 Table 4 A B 1 Patent Number US20200317558A1 2 Patent Title) COVER GLASS 3 Applicant) Nippon Electric Glass Co., Ltd., Shiga (JP) 4 Inventor) Ken YUKI, Shiga (JP); Tomonori ICHIMARU, Shiga P) : Yohei P) : Yohei</th></td<>	Metadata Table 1 Table 2 Table 3 Table 4 A B 1 Patent Number US20200317558A1 2 Patent Title) COVER GLASS 3 Applicant) Nippon Electric Glass Co., Ltd., Shiga (JP) 4 Inventor) Ken YUKI, Shiga (JP); Tomonori ICHIMARU, Shiga P) : Yohei P) : Yohei
signer IDPON ELSCHER Arr 184 Notice Sohject to are discled or adjusted under 35 578,374 USC 154(0) by 0 days. 578,374 598,278 This patent is extended or adjusted under 35 578,374 598,278 This patent is subject to a terminal discussion of the subject to a terminal discussion of termina	$ \begin{array}{c ccccccccccccccccccccccccccccccccccc$	A (r) 2 Al2O3 (mol%) 3 3 B2O3 (mol%) 3 4 Li2O (mol%) 16 5 Na2O (mol%) 00 6 KOMgO (mol%) 00 7 CaO (mol%) 00	(2) C17186 Ker.1, 2018 (3) C77 Ker. FCT2978487299 (3) T171 (x)71, (3) has: Jan, H, 232 (3) Ferdia Application PriorityData (b) Ferdia Application PriorityData (b) Scott (c)	5 Assignee 6 Date 2020-10-08
Prior Publication View 7, 2012 7,687. US 2012/0141760 Al Jun. 7, 2012 7,687.	$\begin{array}{cccccccccccccccccccccccccccccccccccc$	9 JUC (mol/s) 34.5 9 JUC (mol/s) 0.0 10 Z/O2 (mol/s) 0.0 11 Y2O2 (mol/s) 3.5 12 P2O5 (mol/s) 2.0 13 OO (mol/s) 2.0 14 SO2 (re2O3 ppm) (Fe2O3 ppm) 0.0 15 E (GPa 1 (GPa) 0.0 16 Kic (MPa · m*5) (MPa · m*5) 0.0 17 code (mol/s) 0.0 19 JUC (mol/s) 0.0 10 JUC (m	100 90 80 wr(thy) 50 40 30 40 30 40 50 50 50 50 50 50 50 50 50 5	
4	$ \begin{array}{cccccccccccccccccccccccccccccccccccc$	resistance (mol%) 11.013 19 (gf) (gf) 106 20 (Al2O3 BO3 (mol%) 10. 21 X (mol%) N.A. 22	20 10 0 6500 75CD 8500 3500 10500 11500 12500 13500 X	
				31

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Home > Patent Extractio

ML-Modelling Glass Properties

Most efficient input parameters {descriptors}







 $^+P(C_i) = \rho$, E, G, K, v, and DFT and U_{ion}^* Atomic radii and weighs

Data space Glass design tools



	on (Dev)								
🖽 Input UI 🛛 </th <th>> Advanced</th> <th></th> <th></th> <th></th> <th></th> <th></th> <th></th> <th></th> <th></th>	> Advanced								
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		/GlasDigital 🗸	Home	> Glass Prediction					
		I Error Bars Plot	Continuous	Error Bars Plot					
		Property: Dens	sity at 20°C (g/cm³)						
					(50-X) B2O3 - X I	Na2O - 50 SiO2			
Graphs	(74-X) B2O3								SVM
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WT

PMD-S

S BAM

olbniz-Institut für Arkatofforientierte Schnologien





 Complexity & Challenges, but
 First steps regarding all aspects
 Cooperation network established
 After-project cooperation planned



www.materialdigital.de

Thank you for your attention



Fraunhofer Isc Altair Contreras Jaimes Martin Kilo Gerhard Schottner Rick Niebergall Johannes Sorg Andreas Diegeler BAM Tina Waurischk Stefan Reinsch Ralf Müller Andréa de Camargo



Shravya Gogula Hansjörg Bornhöft Joachim Deubener



René Limbach Zhiwen Pan Lothar Wondraczek



Ya-Fan Chen Felix Arendt Marek Sierka







MATERIAI DIGITA



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Visibility

Conferences, Workshops, Fairs



2022

07: ICG, Berlin: Talk (M. Kilo), Poster (T. Waurischk)
09: Achema, Frankfurt: Talk (M. Sierka)
09: MSE, Darmstadt: Talk (Y. Chen), Poster (T. Waurischk)
11: MatFo, Köln: Invited talk (R. Müller)
11: Uni Erlangen: Talk (A. Diegeler)
12: UNO IYOG2022, Tokyo, Closing ceremony: Invited talk (L. Wondraczek)

2023

- 04: OntoCommons Workshop, Berlin: Talk (P. Portella)
- 05: DGG-USTV, Orleans: Talks (R. Müller (invited), M. Sierka, H. Bornhöft, M. Kilo)
- 06: GOMD, New Orleans: Invited talk (A. Diegeler)
- 09: HVG-DGG FA I, Jena: Invited talk (R. Müller)
- 10: Uni Waterloo, Canada: Talk (A. Diegeler)
- 11: Istanbul: Sisecam Conf.: Talk (M. Kilo)
- 11: HVG-DGG Fortbildungskurs, Offenbach: Lectures (R. Müller, M. Kilo, M. Sierka, H. Bornhöft)
- 12: SIPS Conf, Panama: Talk (A. Diegeler)

2024

- 04: Analytica, München: Talk (M. Kilo)
- 05: GTT, Aachen: Talks (T. Waurischk (invited), H. Bornhöft, F. Arendt)
- 06: Symposium Glasapparatebauer, Mitterteich: Invited talk (T. Waurischk)







Visibility Paper

- Pan, Dellith, Wondraczek: Genome Mining in Glass Chemistry Using Linear Component Analysis of Ion Conductivity Data, Adv. Sci. (2023) DOI: 10.1002/advs.202301435
- Arendt, Limbach, Wondraczek, Sierka: Enhancing glass property predictions through ab initio-derived descriptors, JACS (2024) DOI: 10.1111/jace.19904
- O Gogula, Bornhöft, Wondraczek, Sierka, Diegeler, Müller, Deubener: Optical Real-Time Castability Evaluation for High-Throughput Glass Melting, Glass Europe (2024) DOI: 10.52825/glass-europe.v2i.1359
- Chen Arendt Bornhöft Camargo Deubener Diegeler Gogula Contreras-Jaimes Kempf Kilo Limbach Müller Niebergall Pan Puppe Reinsch Schottner Stier Waurischk Wondraczek Sierka: Ontology-based digital infrastructure for data-driven glass development, AEM (under review)
- Diegeler Kilo Contreras-Jaimes Waurischk Reinsch Müller: Digital material data-based glass screening for the systematic development of new glasses, Flogen Proceedings (under review) FRIEDRICH-SCHILLER-UNIVERSITÄT JENA

Fraunhofer

- Bayerlein et al.: A Unified Concept for a Materials Data Space – Insights from the MaterialDigital Initiative, AEM (under review)
- Schaarschmidt et al.: Scientific Workflows within the Initiative MaterialDigita, AEM (under review)
- **O** 4 others in preparation

HVG-DGG

 (\mathbf{r})

- https://github.com/materialdigital/ glasdigital-ontology
- https://git.material-digital.de/yafanchen/fast-ontodocker

für Bildung

und Forschung







https://sciglass.uni-jena.de/database

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		Q Search components	SiO ₂ R ₂ O ₅	Q Search properties				Palukkia V.M. Casimera D.D.	1002 50		Properties	antia 10	
	тм	Oxides A	R ₂ O RO ₃	Acoustical properties		IM 69	214	Makarova LA., Maltseva Z.S., Kormova S.V., Livshits V.Va	Na20	3802, 8203, Al203, L8203,	properties	asuc 19	
			RO Halides	Chemical durability				Potalitsyn M.G., Nakhapetyan R.A.					
			R ₂ O ₃ Others				229	Sang J.C., Jakubik R.F., Barkatt A.	1994 SiO ₂ K ₂ O	Na2O, CaO, MgO, Al2O3, 31O2, Fe2O3	Density, Chemical durability	1	
		B2Q2		Density		<u> </u>	254	Grigoriev V.S., Yakhkind A.K.	1988 SiO2	Al2O2, B2O2, CaO, BaO, Zni	 Density, TEC, T_∞ Optical 	13	
Glass Next	7	BaO	System Type	Dielectric properties					Li ₂ O	Na2O, K2O	properties		C -
		BeO	All	Diffusion, permeation & solubility of cases			258	Livshits V.Ya., Marchuk E.A., Plutalova N.Yu., Shchavelev O.S.	1988 SiO ₂ Nd ₂	B2O3, Al2O3, La2O3, Sb2O3, 3, Na2O, K2O	Densit		
	_	BipOa		Elastic properties		63	287	Gutkina N.G., Nemilov S.V.,	1978	jlass Next			
Glass Next		CaO	Impurities < 0.5wt%	Electrical resistivity	SciGlass No	ext		Polozok N.V., Chernysheva E.O.	Q	41673			
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s SciGlass Next	•	Max MA MA			Mots GN0 Coss Coss	by batch SIO2 72.7 76.2 75.8 76.2 76.5 5	BaOg AlgOg A	Q: Sauch Nago Q: Sauch 143 L203 SB203 NegO3 Nago J: 143 152 J: 4.8 153	 K₂O K₂O K₂O A₃O A₄O 	Sort	50 40 40 40 40 40 40 40 40 40 4	30 48 50 60	
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